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APPLICATION NO.	$\perp$	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/806,224	-	06/11/2001	Hartmut Grutzediek	1477.011	4906	
	7590	08/14/2002				
Jeff Rothenberg				EXAMINER		
Heslin & Rothenberg 5 Columbia Circle				FOONG, SUK SAN		
Albany, NY	12205			ART UNIT	PAPER NUMBER	
				2823		
				DATE MAILED: 08/14/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

			(MV					
	Application No.	Applicant(s)						
	09/806,224	GRUTZEDIEK ET A	L.					
Office Action Summary	Examiner	Art Unit						
	Suk-San Foong	2823						
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply								
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may within the statutory minimum of the will apply and will expire SIX (6) Mid accuse the application to become	a reply be timely filed  nirty (30) days will be considered timely.  DNTHS from the mailing date of this com  ABANDONED (35 U.S.C. § 133).	munication.					
Status								
1) Responsive to communication(s) filed on	_·							
2a) ☐ This action is <b>FINAL</b> . 2b) ☑ Thi	is action is non-final.							
3) Since this application is in condition for alloware closed in accordance with the practice under a Disposition of Claims			merits is					
4) ☐ Claim(s) 1-27 is/are pending in the application								
4a) Of the above claim(s) is/are withdraw								
5) Claim(s) is/are allowed.	on nom consideration.							
6)⊠ Claim(s) <u>1-27</u> is/are rejected.								
7) Claim(s) is/are objected to.								
8) Claim(s) are subject to restriction and/or	r election requirement.							
Application Papers	, , , , , , , , , , , , , , , , , , ,							
9) The specification is objected to by the Examiner	<b>f.</b>							
10)☐ The drawing(s) filed on is/are: a)☐ accep	ted or b)  objected to by	the Examiner.						
Applicant may not request that any objection to the	e drawing(s) be held in abe	yance. See 37 CFR 1.85(a).						
11)☐ The proposed drawing correction filed on	is: a)☐ approved b)☐	disapproved by the Examiner.						
If approved, corrected drawings are required in rep	ly to this Office action.							
12) The oath or declaration is objected to by the Exa	aminer.							
Priority under 35 U.S.C. §§ 119 and 120								
13)⊠ Acknowledgment is made of a claim for foreign	priority under 35 U.S.C	. § 119(a)-(d) or (f).						
a)⊠ All b)☐ Some * c)☐ None of:								
<ol> <li>Certified copies of the priority documents</li> </ol>	s have been received.							
2. Certified copies of the priority documents	s have been received in	Application No						
3. Copies of the certified copies of the prior application from the International Bur * See the attached detailed Office action for a list of the prior application from the prior application	eau (PCT Rule 17.2(a))	•	age					
14) Acknowledgment is made of a claim for domestic	•		pplication).					
a) The translation of the foreign language pro-	visional application has	been received.	FF /					
Attachment(s)								
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 3.	5) Notice of	v Summary (PTO-413) Paper No(s) f Informal Patent Application (PTO-						
Burning and American								

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## **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claim 1 is rejected under 35 U.S.C. 102(b) as being anticipated by Sakurai et al. ('022). Sakurai et al. teaches a method of forming integrated circuit devices such as transistors, diodes and logic gates which includes providing mask 22 onto semiconductor substrate 21 (Page 2, lines 26-30, and Fig. 2), then forming window 23 delimited by peripheral edge (Page 2, lines 31-38, Fig. 3), then performing ion implantation into semiconductor substrate 21 using mask 22 to form n-doped trough 24 with fringe area of trough 24 extending up to semiconductor substrate 21 and with energy that assure n-doped inner area remains on surface of semiconductor substrate 21 (Page 3, lines 1-12, and Fig. 4), and forming additional n-doped areas 27 and 28 in p-doped inner area and in the fringe area of n-doped trough (Page, 3, lines 18-29).

## Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 4. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 5. Claims 2-27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sakurai et al. ('022) as applied to claim 1 above, and further in view of the following comments or Nemoto ('551).

Examiner takes official notice that formation of an external base layer adjacent to the base layer having an impurity concentration that is higher than that of the base layer was known prior to applicant's invention and also disclosed by Nemoto.

It would have been within the scope to one ordinary skill in the art to combine either the known process or that of Nemoto with that of Sakurai et al. because it would enable the formation of a bipolar transistor with p-doped or n-doped area having heavier doping than n-doped or p-doped inner area to be performed.

The choice of particular doping levels for the regions/areas formed would have been a matter of routine optimization to achieve the desired device densities on the finished wafer and the desired device characteristics of the device. (See MPEP 2144.05)

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The recited method of formation of additional devices would have been within the scope

of one ordinarily skilled in the art in view of the disclosure of formation of I<sup>2</sup>L (Page 4, lines 14-

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15), the particular steps recited being conventional at the time of applicant's invention and/or

design choices.

The prior art made of record and not relied upon is considered pertinent to applicant's

disclosure.

6.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Suk-San Foong whose telephone number is 703-305-0383. The

examiner can normally be reached on Monday to Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Wael Fahmy can be reached on 703-308-4918. The fax phone numbers for the

organization where this application or proceeding is assigned are 703-308-7722 (7724, 3431,

3432).

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is 703-308-0956.

August 8, 2002

**Primary Examiner** Art Unit 2823